

Electronic Supplementary Information (ESI)

Air-stable poly(3,3,3-trifluoropropylsilylene) homo- and copolymers

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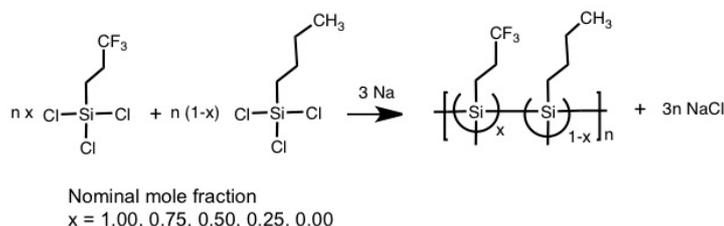
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Experimental section

1. Preparation of FSNP, BSNP, and FBSNP

FSNP and **BSNP** were prepared via the Na-mediated condensation of 3,3,3-trifluoropropyltrichlorosilane (**1**, Shin-Etsu) and *n*-butyltrichlorosilane (**2**, Shin-Etsu), respectively, in hot *n*-nonane without crown ether as a co-catalyst under an N₂ atmosphere in accordance with the previously published procedure.²⁹ **F_xB_{1-x}SNP** (*x* = 0.25, 0.50, and 0.75 in which *x* is the nominal molar fraction of **1**) were produced via Na-mediated co-condensation of **1** and **2** (nominal molar feed ratios: 0.25/0.75, 0.50/0.50, and 0.75/0.25) in a manner similar to that used for the synthesis of **FSNP** and **BSNP**. To avoid contact with air and moisture during the work-up processes, including the preparation, isolation, and sealing of the samples in glass tubes, we typically synthesized **FSNP** in the following manner, as shown in Scheme 1.



Scheme 1. Synthetic scheme for **FSNP** (*x* = 1.00), **BSNP** (*x* = 0.00), and **F_xB_{1-x}SNP** (*x* = 0.25, 0.50, and 0.75 in a nominal feed fraction of **1** to **2**).

A 20-mL solution of *n*-nonane (Aldrich, dried over 4A molecular sieves) that contained Na (Wako, 2.3 g, 0.10 mol) was placed in a four-necked 100-mL flask and refluxed at 120 °C with vigorous stirring at 800 rpm by a mechanical stirring motor with a glass blade. To this mixture, **1** (5.0 g, 22 mmol) was added dropwise with gentle stirring (800 rpm). After the addition was completed, the reaction mixture was gently stirred at 200 rpm for 2 h and was subsequently allowed to cool to room temperature. The reaction vessel was moved to a glove box that was filled with 99.9% pure N₂ gas.

After 20 mL of THF was added to the reaction mixture and the reaction mixture was subjected to pressured filtration using a fluorinated membrane filter (Whatman, 0.47 μm pore) to remove the NaCl byproduct and unreacted Na, a clear pale-yellow THF/*n*-nonane solution that contained **FSNP** was obtained. Solid samples were yielded by volatilization of the solvents in the glove box. **FBSNP** and **BSNP** were prepared in a similar manner, as outlined in Table S1 in Supporting Information (SI)†. Fourier-transform infrared (FT-IR) signals due

to the $\nu_{\text{as}}(\text{Si-O-Si})$ asymmetric stretching mode at approximately 1000–1100 cm^{-1} and the $\nu_{\text{s}}(\text{Si-O-Si})$ symmetric stretching mode at 800 cm^{-1} in fresh **FSNP**, **FBSNP**, and **BSNP** samples were not observed.⁴⁵ The isolated yield of these **SNPs** was typically 40–50% when the crude **SNPs** were precipitated into methanol outside of the glove box with no precautions taken against air or moisture exposure. This yield was almost identical to that in a previous report of the synthesis of **SNP** with *n*-hexyl groups that was prepared using Na-K alloy under ultrasound irradiation.²³ When the work-up process in the glove box was employed, not all yields were determined to avoid any contact with contaminants during the weighing of the samples.

2. Preparation of FSNP films

Into a synthetic quartz glass tube (ID 5 mm, OD 7 mm), 40 μL of a THF solution that contained **FSNP**, **SNP**, and **FBSNP** (1 g mL^{-1}) was placed.²⁹ The samples were manually coated onto the inner wall of the tube and were dried with flowing N_2 gas. The films deposited inside the glass tubes were connected to a two-way vacuum bulb. The tubes were removed from the glove box and sealed outside the box using a vacuum technique and a torch [~ 0.3 Torr by a rotary pump (ULVAC, Tokyo, Japan) and $\sim 5 \times 10^{-5}$ Torr by a custom-made turbo molecular pump (Torr Science, Kanagawa, Japan)].

3. Characterization and instrumental measurements

The weight-average molecular weight (M_w), number-average molecular weight (M_n), and polydispersity index ($PDI = M_w/M_n$) of five isolated **SNPs** are given in Table S1. The values of M_n and M_w were evaluated by size-exclusion chromatography (SEC) using a UV–vis photodiode array detector at 40 °C based on a calibration with polystyrene standards on a Shimadzu A10 instrument. The SEC was performed using PLgel 10 μm mixed-B (Varian) as the column and THF as the eluent. The UV–vis absorption spectra were recorded on a JASCO V-570 spectrophotometer (bandwidth: 1 nm, scanning rate: 100 nm/min, data sampling: 0.5 nm interval). PL and photoluminescence excitation (PLE) spectra in the range of 370 to 900 nm were measured using a JASCO FP-6600 spectrofluorometer (bandwidth: 3 nm for excitation and 2 nm for emission, response time: 1 sec, sensitivity for photomultiplier tube: high, scanning rate: 100 nm/min, data sampling: 1 nm interval) equipped with a housing designed for phosphorescence equipment that was immersed in liquid N_2 . FT-NMR spectra (^1H , ^{19}F , and ^{29}Si) were measured with a JEOL JNM-LA 400 NMR spectrometer. Chemical shifts were referenced to internal tetramethylsilane and trichlorofluoromethane. FT-IR spectra were obtained on a Horiba FT-730 spectrometer (resolution: 0.5 cm^{-1} , acquisition: 64 scans) by casting a solution of the polymers onto a KBr plate under a N_2 atmosphere. Laser Raman spectra were obtained on a JASCO NRS-2100 (Ar CW-laser 514.5 nm, 10 mW) using the back-scattering mode (acquisition: 50 scans). The polymers were sealed in a glass tube and/or placed onto an Au-coated plate under N_2 atmosphere for measurement. High-resolution transmission electron microscopy (HR-TEM) images were obtained with a JEOL JEM-3100FEF electron microscope (accelerating voltage: 300 kV, bright image mode). X-ray photoelectron spectroscopy (XPS) and analysis was performed on a Kratos Axis 165 (Al- $K\alpha$, 10 mA, 15 kV). Electron energy-loss spectroscopy (EELS) was conducted with a JEOL EM-Z01299TJEC. Specimens for HR-TEM/EELS were prepared by casting a THF solution onto an elastic carbon-film-coated microgrid (Oken-Shoji, Tokyo, Japan). Differential scanning calorimetry (DSC) measurements were conducted on a DSC/TG-DTA 6200 (SII Nanotechnology, Tokyo). Wide-angle X-ray diffraction (WAXD) data were obtained on a Rigaku R-AXIS-IV wide-angle X-ray

diffractometer (Ni-filtered CuK α , 45 kV, 50 mW) and were analyzed using the Rigaku automatic X-ray imaging software.

4. Electronic state calculations using Gaussian03⁴⁴

Electronic state calculations of *trans*-perhydrosiladecaline that was partially substituted with TFP and *n*-butyl groups as models of **FSNP** and **BSNP** were employed using the time-dependent (TD)-density function theory (DFT) [Gaussian03 program (B3LYP, 6-31G* basis sets)] running on an Apple iMac (Intel CoreDuo2, 2.0 GHz, 4 GB memory, MacOS ver.10.5.8). For the calculations, the geometries of parent siladecaline were initially optimized at the PM3-MM level of Gaussian03 using standard parameters (default) with an Si-Si bond length of 2.34 Å and an Si-Si-Si bond angle of 111°.

Table S1. Synthetic conditions for **FSNP**, **BSNP** and **F_xB_{1-x}SNP**.

| Polymer | 1 (FSi) , g | 2 (BSi) , g | Na, g | <i>n</i> -Nonane, mL | M_w^a | PDI $= M_w/M_n^a$ |
|----------|--------------------|--------------------|-------|----------------------|---------|------------------------|
| x = 1.00 | 5.0 | 0.0 | 2.3 | 20 | 2.83 | 1.10 |
| x = 0.75 | 2.4 | 1.0 | 1.6 | 20 | 3.95 | 2.60 |
| x = 0.50 | 1.0 | 0.8 | 0.8 | 20 | 5.30 | 1.22 |
| x = 0.25 | 0.6 | 2.4 | 1.2 | 20 | 5.41 | 1.48 |
| x = 0.00 | 0.0 | 2.5 | 1.0 | 20 | 11.8 | 5.12 |

^{a)} These values were based on a calibration using polystyrene standards.

Table S2. Atomic fractions of **FSi** and **BSi** by ¹H NMR and XPS analyses.

| FBSNP by nominal fraction | Atomic concentration (atomic fraction) | |
|-------------------------------------|--|--------|
| | by ¹ H NMR | by XPS |
| x = 0.75 | 0.47 | 0.50 |
| x = 0.50 | 0.28 | 0.25 |
| x = 0.25 | 0.10 | 0.12 |

Table S3. Quantum yield (Φ_F) of **FSNP**, **BSNP** and **F_{0.5}B_{0.5}SNP** excited at 366 nm in THF at room temperature.

| Polymer | Φ_F / % |
|----------|--------------|
| x = 1.00 | 3.0 |
| x = 0.50 | 1.9 |
| x = 0.00 | 1.1 |

^{a)} These values were based on a calibration with 9,10-diphenylanthracene and were corrected for refractive index.

Table S4. Thermogravimetric (TG) data of **SNPs** in a stream of N₂ gas with a heating rate of 10 °C min⁻¹.

| Polymer | Decomposition /°C | | Weight loss /% | |
|----------|-------------------|--------------|----------------|-----------------------|
| | $T_{d, start}$ | $T_{d, end}$ | □□□ | Calc. as elemental Si |
| x = 1.00 | 285 | 563 | 74 | 77.6 |
| x = 0.50 | 320 | 541 | 62 | 73.3 |
| x = 0.00 | 344 | 445 | 46 | 67.1 |

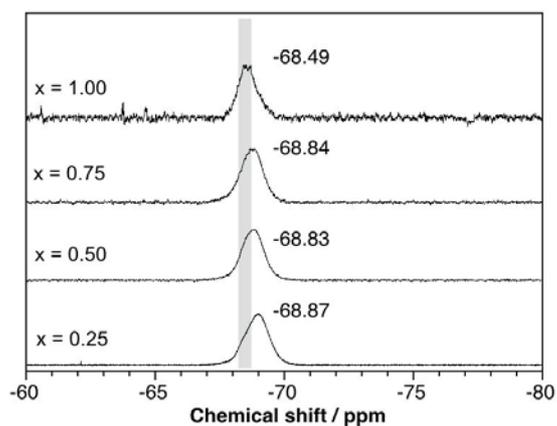


Fig. S1 ^{19}F NMR spectra of FSNP and $\text{F}_x\text{B}_{1-x}\text{SNPs}$ ($x = 0.25, 0.50, 0.75$) in CDCl_3 at 25°C .

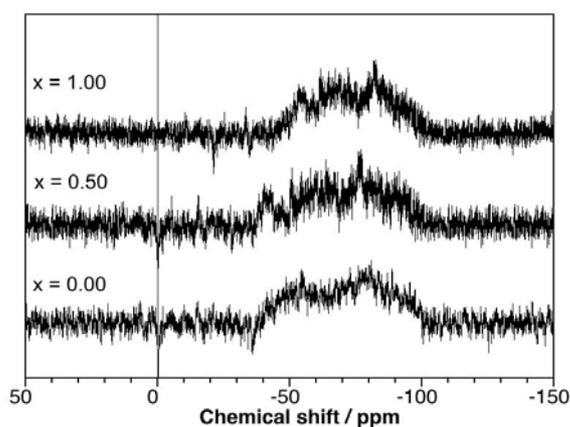


Fig. S2 ^{29}Si NMR spectra of FSNP, $\text{F}_x\text{B}_{1-x}\text{SNP}$ ($x = 0.50$) and BSNP in CDCl_3 at 25°C .

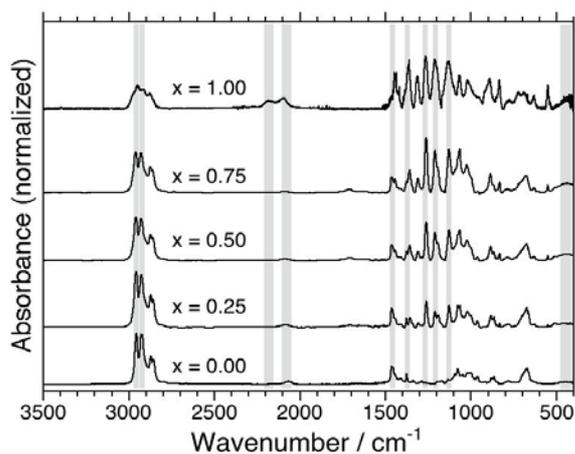


Fig. S3 IR spectra ($3500\text{--}400\text{ cm}^{-1}$) of FSNP, $\text{F}_x\text{B}_{1-x}\text{SNP}$ ($x = 0.25, 0.50, 0.75$) and BSNP cast onto KBr plates.

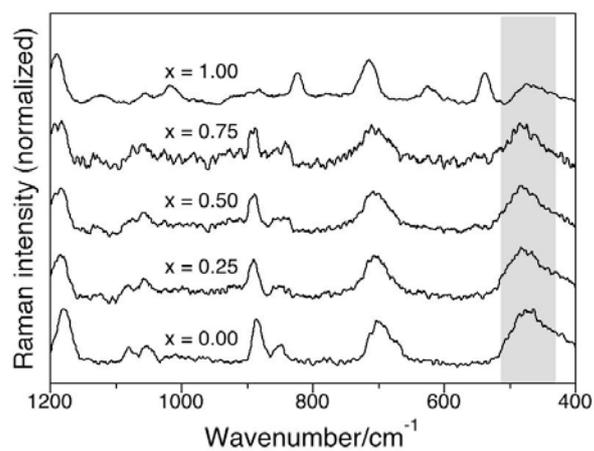


Fig. S4. Raman spectra of FSNP, F_xB_{1-x}SNP (x = 0.25, 0.50, 0.75) and BSNP cast onto Au.

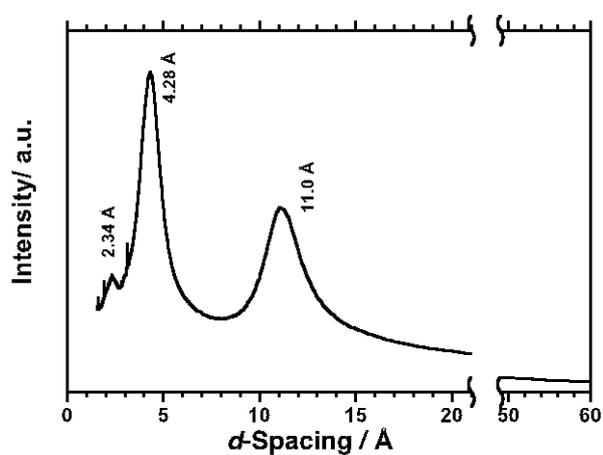


Fig. S5 WAXD data in *d*-spacing of an FSNP film in air.

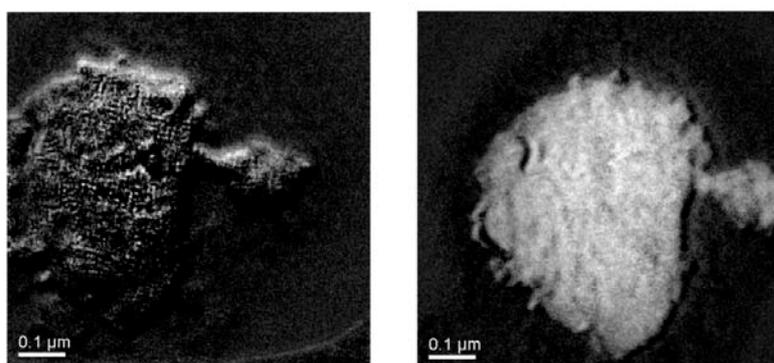


Fig. S6 EELS Si mapping (left) and F mapping (right) images of FSNP on a carbon microgrid (scale bar = 0.1 μm).

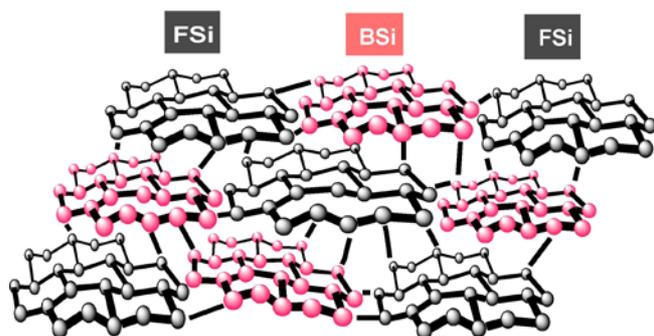


Fig. S7 A proposed structure of **FBSNP** with domain-like segregation (gray and magenta are trifluoropropylsilane and n-butylsilane moieties, respectively).

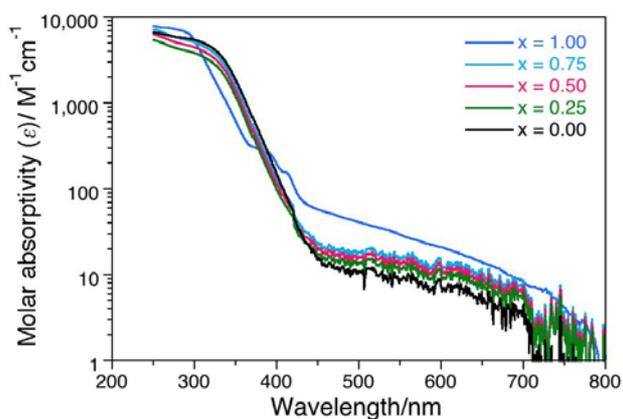


Fig. S8 Semi-log UV-vis absorption spectra of **FSNP**, **BSNP** and **F_xB_{1-x}SNP** ($x = 0.25, 0.50, 0.75$) in THF at 25 °C.

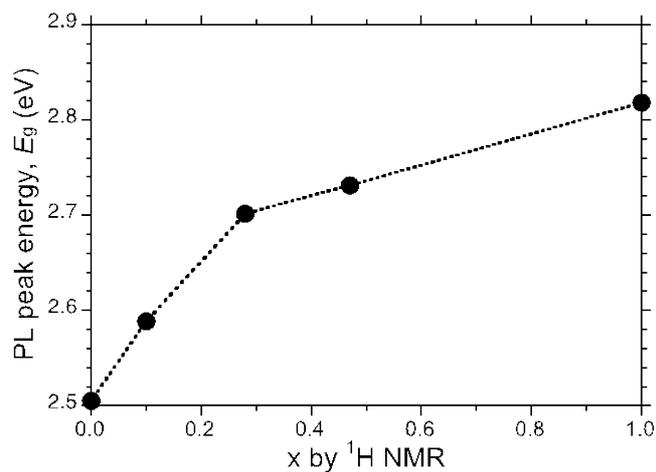


Fig. S9 PL peak energy (in eV) of five **SNPs** in THF excited at 360 nm at 25 °C as a function of the FSi fraction (x) in **SNPs** evaluated by ^1H NMR (taken from Table 1). For $x = 0$, a shorter PL peak wavelength at 495 nm was adopted.

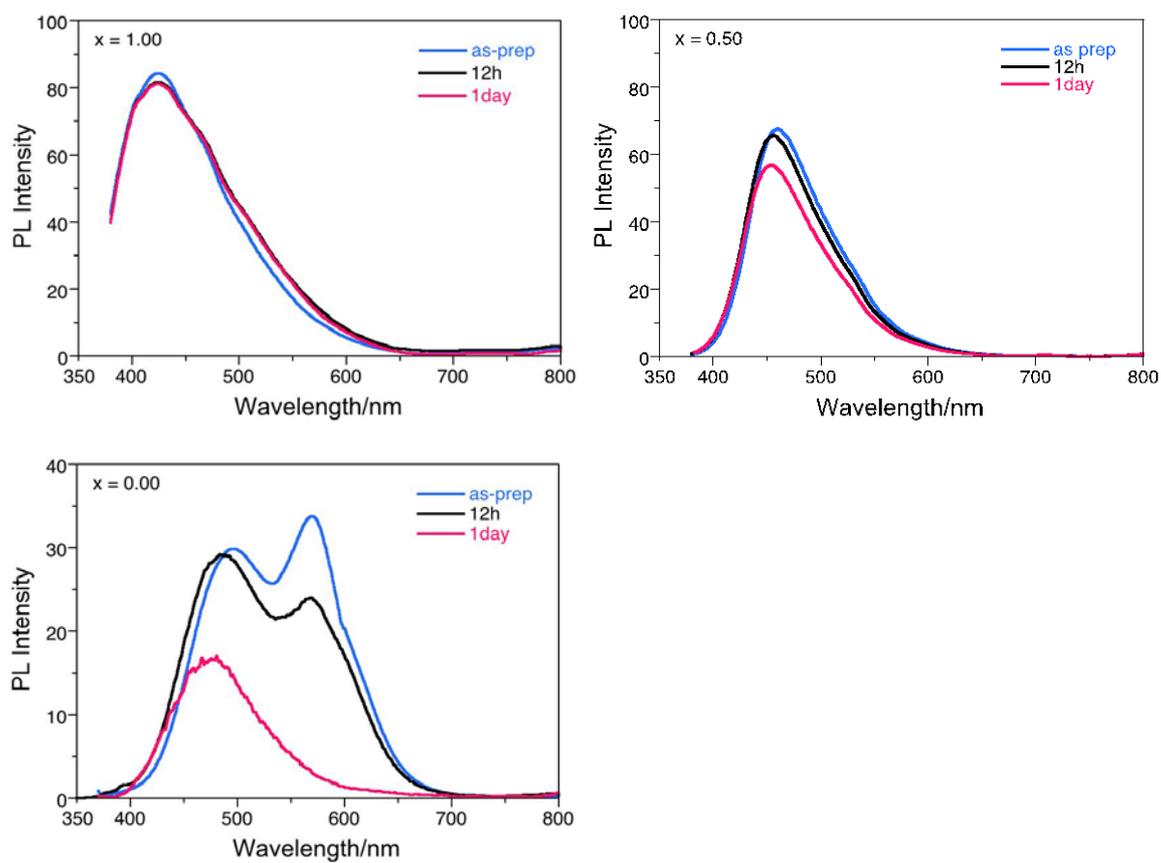


Fig. S10 Changes in the PL spectra of **FSNP**, **B_{0.5}S_{0.5}NP** and **BSNP** in a THF–water (90/10 (v/v)) solution after storage for various times.

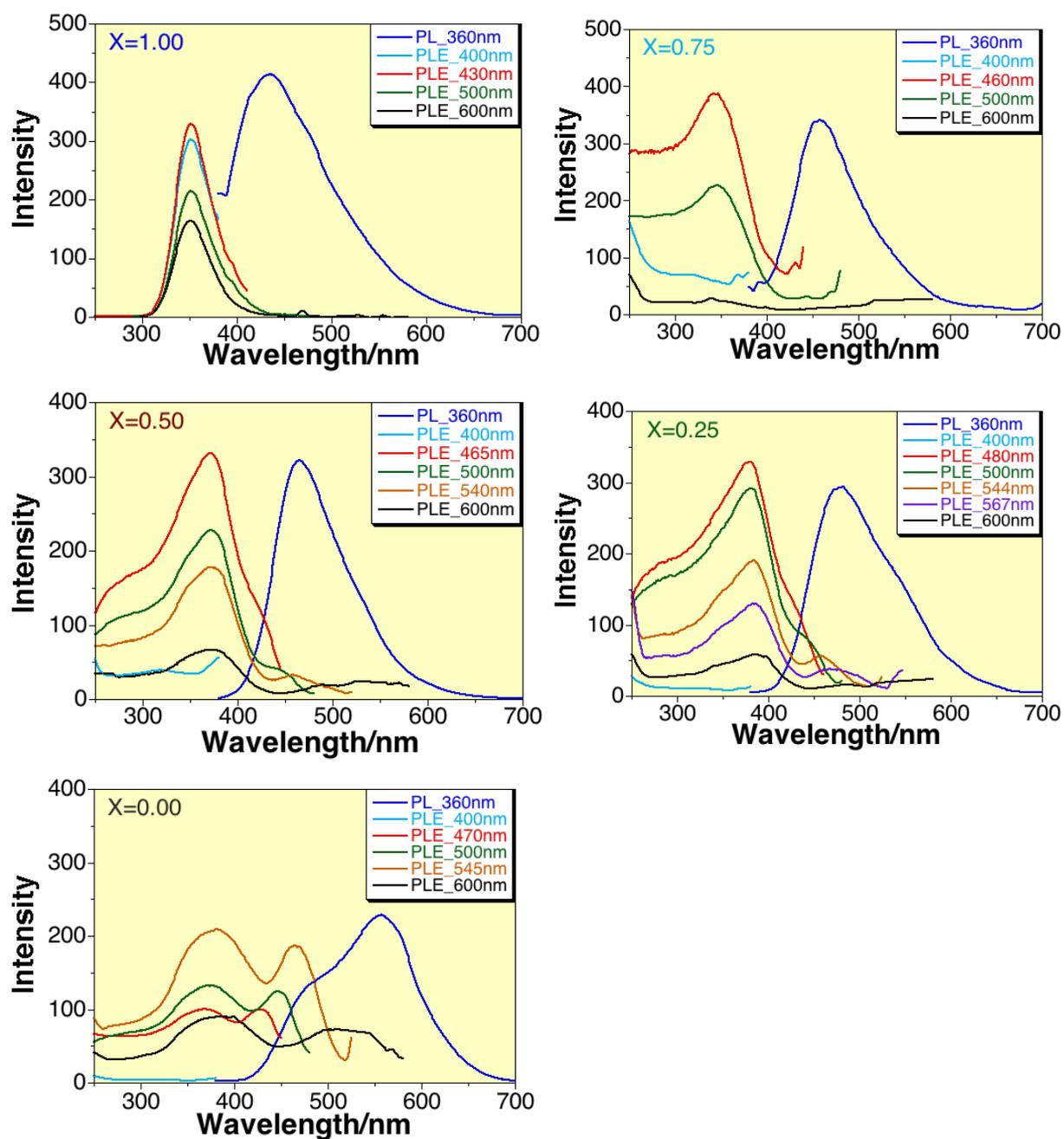


Fig. S11 PLE spectra (excited at 360 nm) of thin films of FSNP , SNP and $\text{F}_x\text{B}_{1-x}\text{SNP}$ ($x = 0.25, 0.50, 0.75$) under vacuum at 77 K.

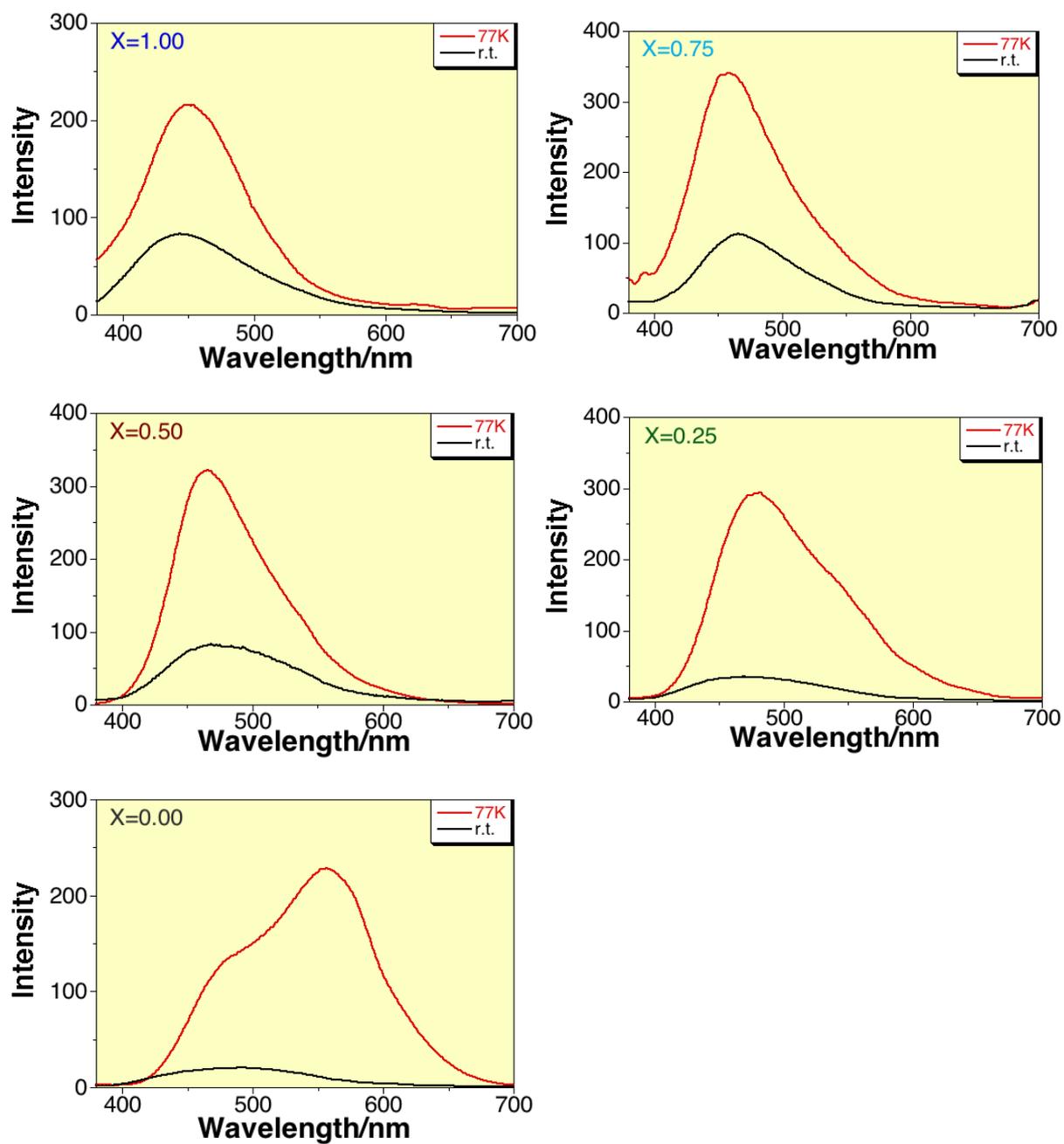


Fig. S12 PL spectra (excited at 360 nm) of thin films of FSNP, BSNP and F_xB_{1-x} SNP ($x = 0.25, 0.50, 0.75$) under vacuum at 77 K and at room temperature.

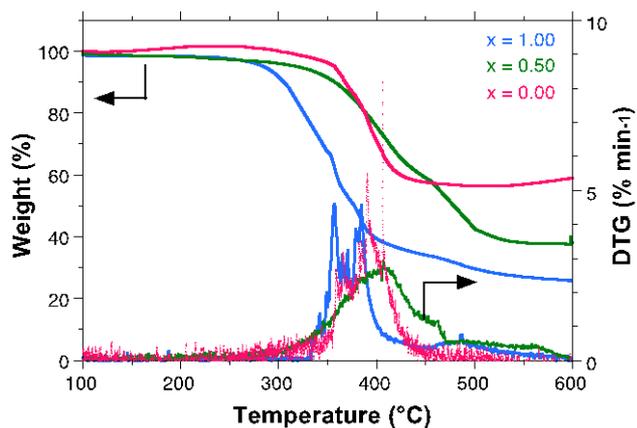


Fig. S13 Thermogravimetric (TG) and differential TG (DTG) charts of **FSNP**, **BSNP** and **F_{0.5}B_{0.5}SNP**

under an N₂ atmosphere with heating rate of 10 °C min⁻¹.

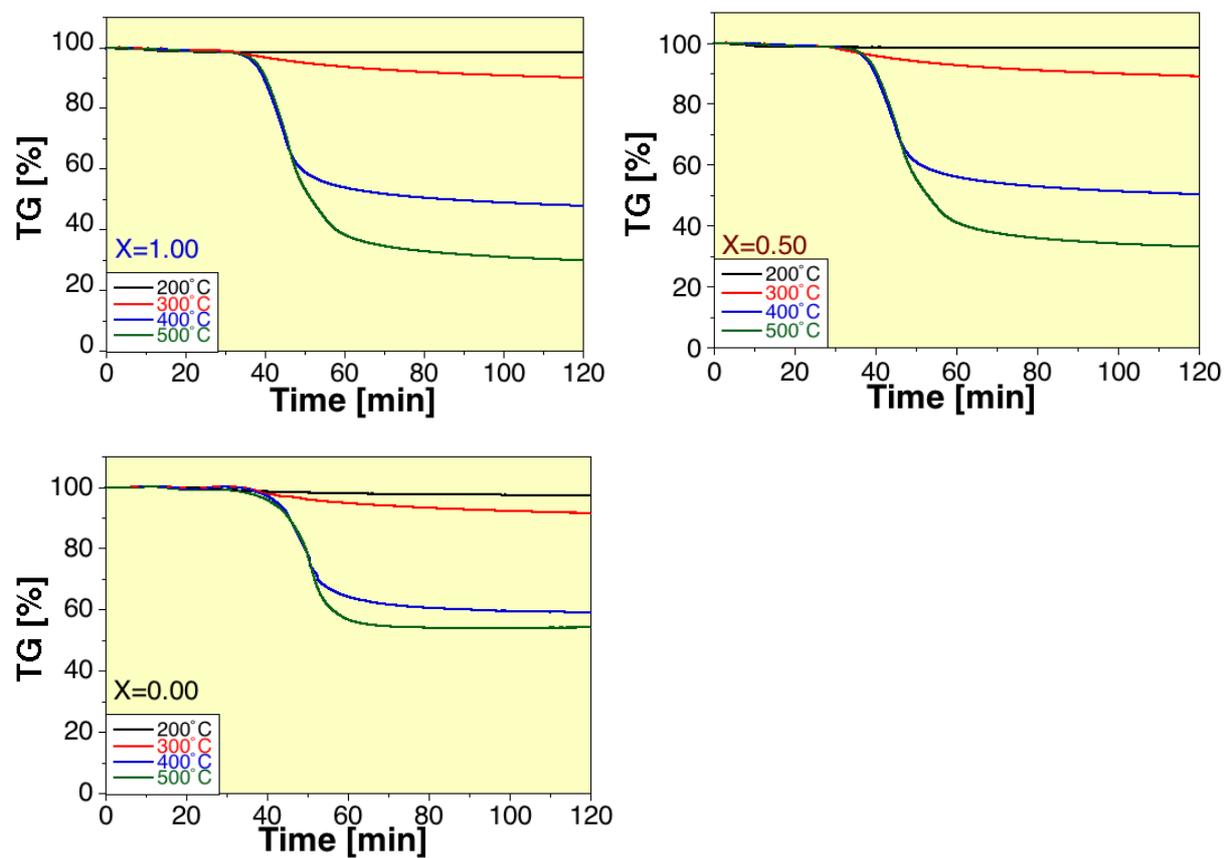


Fig. S14 TG and ITG curves of polymer (sample amount: ca. 1 mg in N₂).

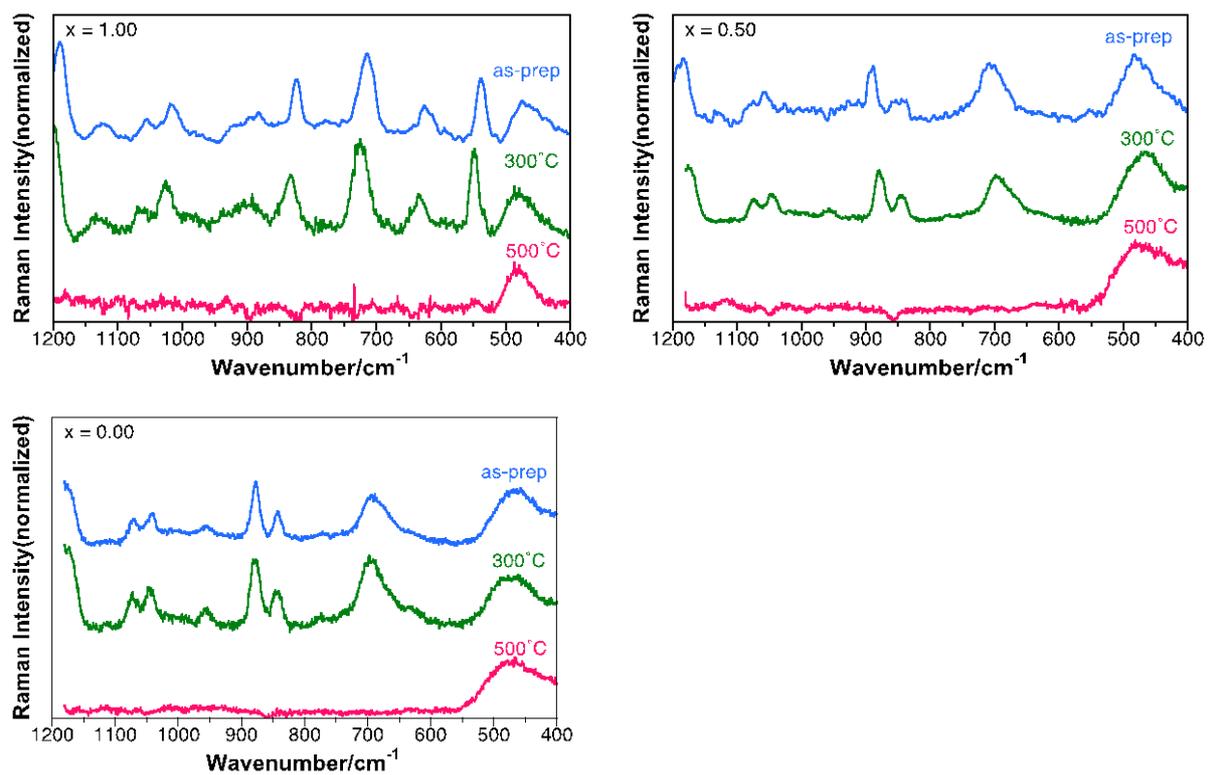


Fig. S15 Raman spectra of **FSNP**, **BSNP** and **F_{0.5}B_{0.5}SNP** pyrolyzed at 300 and 500 °C for 90 min under an N₂ atmosphere.

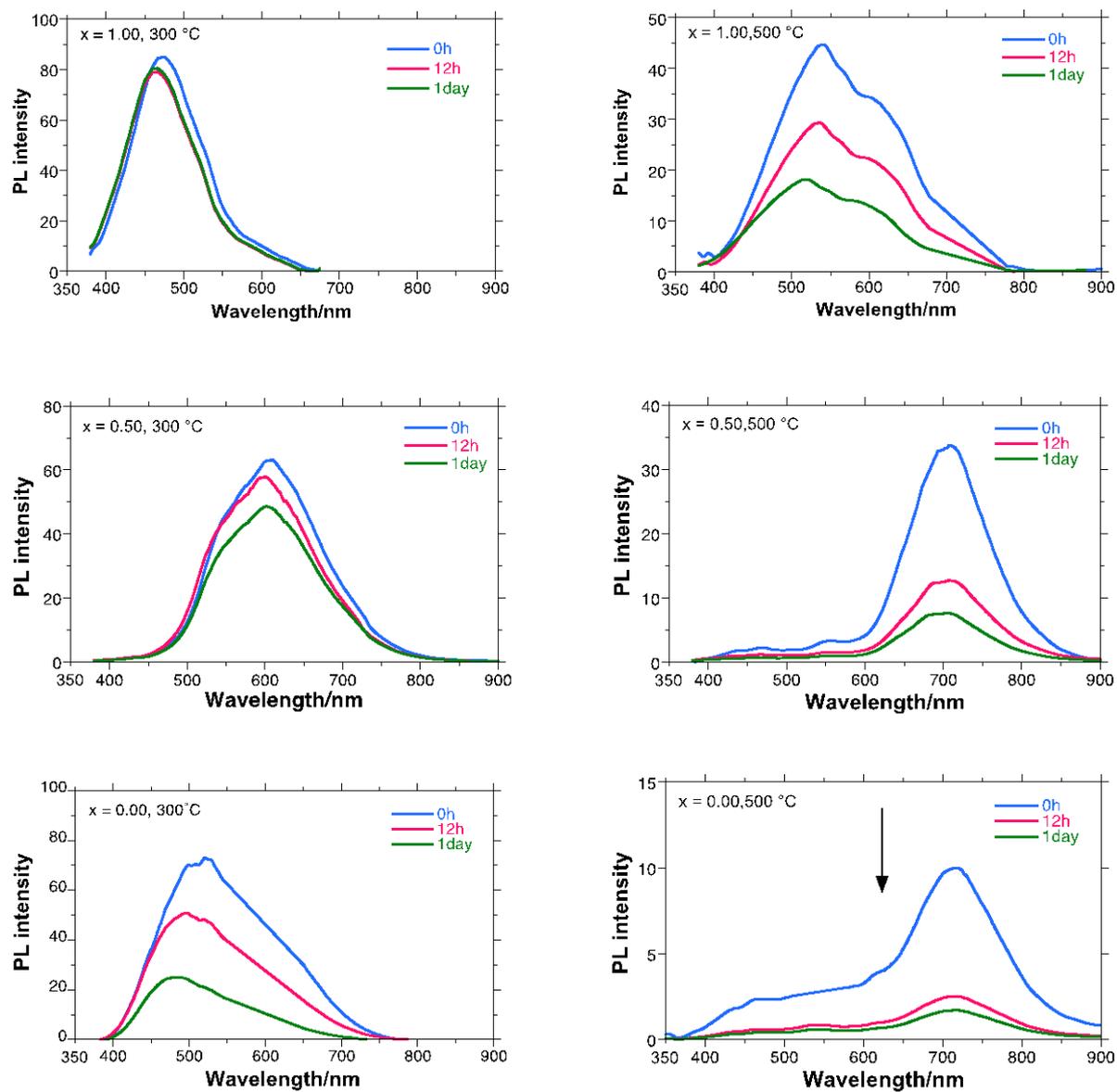


Fig. S16 Changes in the PL spectra of pyrolyzed SNP films in THF–water (90/10 (v/v)) solution after storage for various times. The samples are **FSNP**, **F_{0.5}B_{0.5}SNP** and **BSNP**. The samples were pyrolyzed at 300 and 500 °C for 90 min under vacuum (5×10^{-5} Torr).

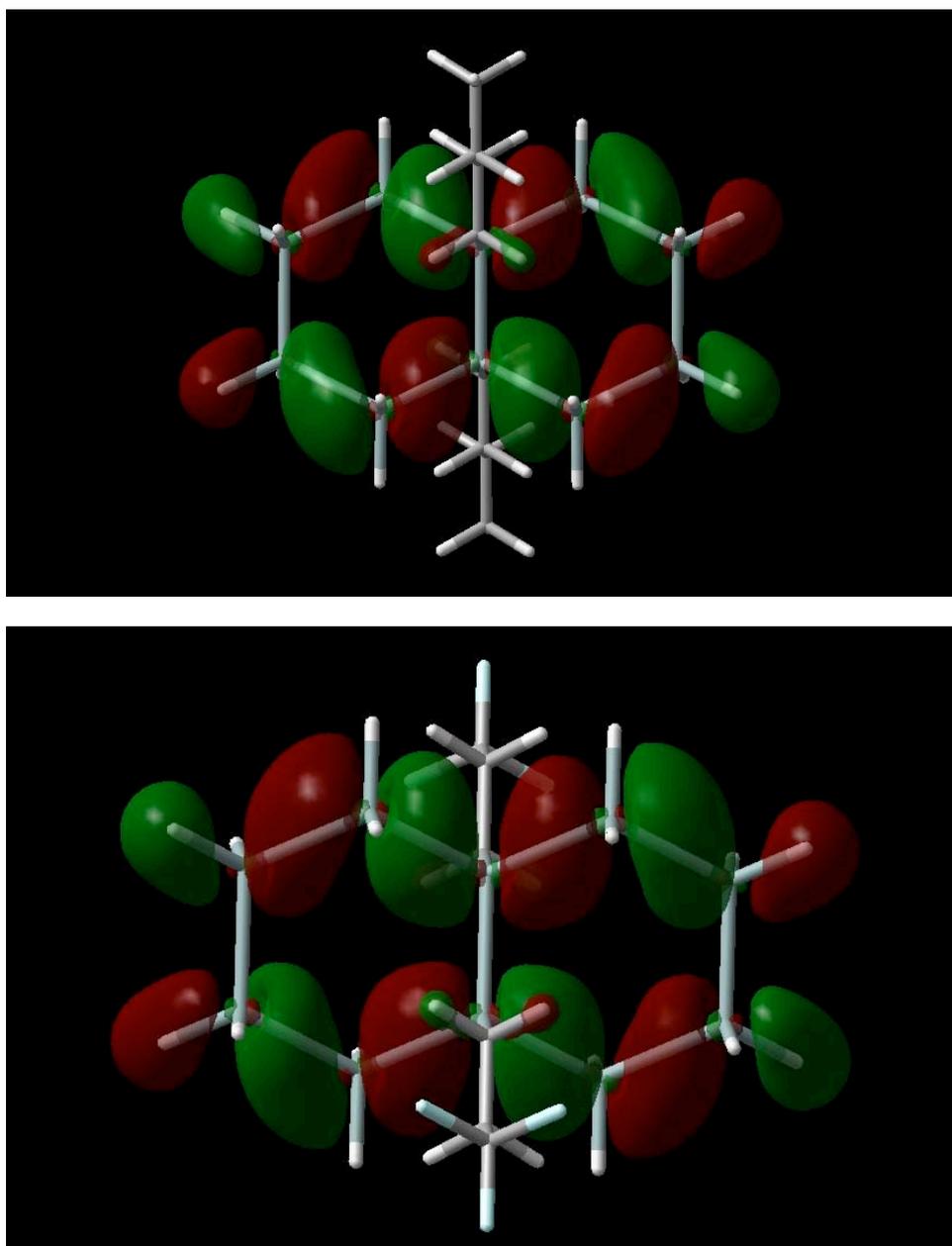


Fig. S17 The first HOMO of (top) **3** and (bottom) **4**.